

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of: LAMARRE, Philip A.

Group Art Unit: 1756

Serial No. 10/710,023

Examiner: DUDA, Kathleen

Filed: 06/14/2004

Dkt No: 20030146-US

For: LITHOGRAPHIC SEMICONDUCTOR MANUFACTURING USING A
MULTI-LAYERED PROCESS

To: Mail Stop AF
Commissioner for Patents
PO Box 1450
Alexandria, VA 22313-1450

From:

42716

Commissioner:

AFTER-FINAL OFFICE ACTION RESPONSE
AMENDMENT

INTRODUCTORY COMMENTS

In response to the Office's Advisory Office Action dated 01/12/2007 the Applicant has timely enclosed herein: 5 pages Office Action Response and authorization to charge 1 month extension to deposit account **190130**. Please amend the above-identified application as follows:

Amendments to the Claims are reflected in the listing of claims which begins on page 2 of this paper.

Remarks/Arguments begin on page 5 of this paper.

[X] DEPOSIT ACCOUNT **190130** AUTHORIZATION – The Office is hereby authorized to charge the required fee, and any deficiency or credit any overpayment in the fees to the above deposit account, owned by BAE SYSTEMS Information and Electronic Systems Integration Inc. an authorized signator for which is Kevin M. Perkins, V.P. & Company Counsel, and for whom the undersigned are authorized agents.